Instabilities simulation and observation

K. Ohmi, J. Flanagan, H. Fukuma, Y. Funakoshi, H. Ikeda, Y. Suetsugu, S. Terui, M. Tobiyama, D. Zhou
21-th KEKB Accelerator Review Committee
KEK, 13-15 June, 2016

Contents

- Beam size blow-up due to Electron cloud
- Coupled bunch instability due to electron cloud
- Coupled bunch instability in HER
- Tune shift measurement and transverse impedance
- Bunch length measurement

Beam size blow-up in LER

- Beam-size blowup observed in KEKB has been seen in early stage of SuperKEKB commissioning
- 1. Threshold I~300mA in Apr 19 (Y. Funakoshi)
- 2. Electron cloud has been monitored at AL chamber w and w/o TiN coating (Y. Suetsugu).
- 3. Beast study threshold I~600mA, N_{bunch}=1576 in May 17 (Nakayama et al)
- 4. Systematic study in 1 June (H. Fukuma et al.)
- 5. Permanent magnets are set at aluminum bellows.(Y. Suetsugu et al.)
- 6. Systematic studies in 8 July (H. Fukuma et al.)



June 1, 2016 4 train x150 bunches, N_{bunch}=600

Threshold beam current 160, 200, 260,500 mA for 2, 3, 4, 6 bucket spacing

H. Fukuma et al.,

Instability simulation at SuperKEKB design stage

• Using code PEHTS



where
$$K = \omega_e \sigma_z / c = 17$$
 and $Q = min(\omega_e \sigma_z / c, 10)$

Design target for vacuum system: $\rho_e{<}10^{11}$ m $^{-3}$ in average of whole ring

Simulation studies using beam study condition

Threshold of the electron density ε_x =2nm, ε_v =15pm, σ_z =6mm, v_s =0.019







Np=2.4x10¹⁰, ϵ_{y} =100pm

Simulated threshold electron density (condition before solenoid installation)

• N_b=600, ε_x =2nm, ε_y =15pm, σ_z =6mm, v_s =0.019

spacing	l _{p,th} (mA)	N _{p,th} (10 ¹⁰)	ω _e /2π (GHz)	ω _e σ _z /c	ρ _{eth} (Q=10) (10 ¹¹ m ⁻³)	ρ _{eth} (Q=6) (10 ¹¹ m ⁻³)	ρ _{eth} (Simu) (10 ¹¹ m ⁻³)	
2 (4ns)	160	1.6	61	7.7	1.91	2.45	3.4	
3 (6ns)	200	2.1	71	8.9	1.65	2.45	3.4	
4 (8ns)	260	2.7	80	10.1	1.47	2.45	3.8	
6 (12ns)	500	5.2	111	14.0	1.47	2.45	5.0	
3.06	500	2.0	37	5.5	2.89	2.90	4.4	N _b =1576,
3.06	600	2.4	41	6.0	2.63	2.65	4.4	ε _y =100pm

$$\rho_{e,th} = \frac{2\gamma\nu_s\omega_e\sigma_z/c}{\sqrt{3}KQr_0\beta L}$$

 $K = \omega_e \sigma_z / c$ $Q \models \min(\omega_e \sigma_z / c, \mathbf{6})$

Electron cloud measurement



- Retarding bias, V=500V or 0V, select electrons with E>500eV or all, respectively.
- Electron E=500eV, v=1.3x10⁷m/s. R/v=3.8ns, R=5cm, density can be estimated considering volume with energy gain 500eV from a bunch. 500eV may be critical for 2 (4ns) spacing.
- For V=0V, electron rate production including secondary is detected.



For V=0V, 1µA, electron production rate is 0.3×10^9 m⁻¹/bunch

Electron density at the blow-up threshold



After installation of permanent solenoid at Al bellows



X Simulated electron density at the threshold current

Threshold of electron cloud density after solenoid attach

spacing	l _{p,th} (mA)	N _{p,th} (10 ¹⁰)	ω _e /2π (GHz)	ω _e σ _z /c	ρ _{eth} (Q=10) (10 ¹¹ m ⁻³)	ρ _{eth} (Q=6) (10 ¹¹ m ⁻³)	ρ _{eth} (Simu) (10 ¹¹ m ⁻³)
2 (4ns)	200	2.1	71	8.9	1.65	2.45	3.4
3 (6ns)	330	3.5	91	11.5		2.45	4.8
4 (8ns)	>600	>6.3					
6 (12ns)							
3.06	500	2.0	37	5.5	2.89	2.90	4.4
3.06	600	2.4	41	6.0	2.63	2.65	4.4

Simulated electron cloud build up in Drift



E cloud buildup

CLOUDLAND, Fukuma



Coupled bunch instability caused by electron cloud

- Electron cloud motion reflects coupled bunch instability mode.
- Electrons in drift, short range wake ~10ns
- Electrons in solenoid, slow rotation around chamber surface.



Unstable mode (before solenoid installation)

 Typical signal of coupled bunch instability caused by drift electrons



Mode spectrum

By 2 ver 300mA



400mA



By 4 ver 350mA



600mA



Unstable mode (after solenoid installation)

- Typical mode caused by electrons in solenoid is seen.
- Mode seems to change to those of drift origin at high current.





Coupled bunch instability in electron ring (HER)



Impedance estimation-transverse

• Tune shift as function of bunch current



coll. open 33-46 k Ω /m T. leiri, EPAC00

Longitudinal impedance issue-Bunch length measurement



Measured by a Streak camera

The behaviors are similar as KEKB for both of LER and HER. Bunch lengthening is stronger than that of simulation.

Summary

- Beam size blow-up has been observed since early stage of SuperKEKB commissioning.
- Electron density at Al bellows part (5% of circumf.) is high $(\rho_e > 10^{12} m^{-3})$. Simulations show the electrons can cause fast head-tail instability.
- Coupled bunch instability caused by electron cloud has also been observed as is predicted.
- Installation of Permanent solenoid reduced the blow up. It is possible to operate with 1A, 4 bucket spacing at present condition.
- Tune shift as function of bunch current was measured to estimate transverse impedance. It was 30-50k Ω/m , similar as KEKB.
- Bunch length was measured by a streak camera. Bunch lengthening, which was similar as KEKB, was observed, 7-8 mm at the design current, while no bunch lengthening in prediction.

Thank you for your attention

Rough estimation of Electron density

- Electron current, $I_e = 1 \mu A$.
- Acceptance of the electron detector, $S_{mon}=1$ cm².
- Number of electron absorbed (=produced) at chamber wall, d=10cm.

$$n_e = \frac{10^{-6} \times 0.1\pi}{1.6 \times 10^{-19} \times 10^{-4}} = 2 \times 10^{16} \ m^{-1} s^{-1}$$

- Electron stay time in the chamber, $\tau_{\rm e}\text{=}100\text{ns}.$ Electron density

$$\rho_e = \frac{2 \times 10^{16} \times 10^{-7}}{0.05^2 \pi} = 2.5 \times 10^{11} \, m^{-3}$$

Emittance dependence

• Vertical emittance knob



Design current & spacing

Np=9.4x10¹⁰, I=3600 mA



金澤氏の式を使った電子密度の算出*

まとめると、

$$D = 2.630 \text{E13 x} \quad \frac{I_{obs} n_b V_b}{I^2}$$

例えば、2/150/3 V_r = -30 V, I = 200 mA, I_{obs} = 1E-7 A の場合 (平均で)

 $n_b = 600, V_b = 30$ $D = 1.18E12 [e^{-} m^{-3}]$

Simulated electron cloud build up in Bend



Multipactoring arises Y_{2max} >=1.5 at the threshold beam currents.

